

Brief Biodata

Name: Unnikrishnan V T

Designation:	Scientist	
DP No. and Name:	7.05 - Intellectual Property Rights Management Group	
DU No. and Name:		
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Date of Joining CSIR-NPL:	09 December 2020	
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Research Area/ Interest

Working with scientists in different domains and guiding them in intellectual property matters. Managing the IP-portfolio of the lab. Working for intellectual property integrated innovation management. Working with different strategic initiatives such as competitive intelligence, technology landscaping, whitespace analysis, disruptive technologies identification. Techno-legal activities such as patentability analysis, freedom to operate analysis, invalidity searches and defensive publications.

Educational Qualifications

Degree	Subject	University/ Institute	Year
M.Tech	Instrumentation and Control Systems	National Institute of Technology (NIT), Calicut	2013-2015
B.Tech	Electrical and Electronics Engineering	University of Kerala	2007-2011

Academic / Research Experience

Grade / Post	Institute/Organization	Duration		Research Field
		From	To	
Intellectual Property Analyst	Honeywell Technology Solutions	2015	2020	Intellectual Property
Systems Engineer	TCS	2011	2015	Big Data

Current Activities

- Working for Intellectual Property Rights Management Group.
- Providing guidance to scientists regarding the patenting process and facilitating them to obtain the best refined intellectual property. Providing guidance to researchers and scientists to choose the right intellectual property.
- Have strong knowledge of Indian patent acts and have experience in managing the IP-portfolio of the laboratory.

Honour(s)/Award(s)/ Fellowship(s)

Registered Indian Patent Agent – IN/PA-4594

‘Bravo Award’ from Honeywell for automating the patent status extraction process by using java and selenium.

‘Innovation Award’ from Honeywell for developing the idea for battery charging for unmanned aerial vehicles.

‘Award for Excellence’ from TCS for demonstrating continued dedication required to achieve excellence and success.